

Semiconductor Oxidation Furnaces Market - Forecast from 2026 to 2031

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Abstracts

Semiconductor Oxidation Furnaces Market, sustaining a 5.57% CAGR, is anticipated to reach USD 1.571 billion in 2031 from USD 1.135 billion in 2025.

Semiconductor oxidation furnaces – encompassing horizontal and vertical thermal processing systems – remain foundational equipment for gate oxide, field oxidation, and passivation layer formation in both silicon and compound-semiconductor device fabrication. These tools deliver precisely controlled dry and wet thermal oxidation, annealing, and dopant drive-in processes essential for logic, memory, analog, and power devices. Demand is increasingly shaped by the proliferation of electric-vehicle powertrains, advanced driver-assistance systems (ADAS), 5G RF components, and industrial automation platforms, all of which require high-quality dielectric and passivation layers.

Primary Growth Drivers

1. Sustained expansion of consumer and automotive electronics Rising global shipments of smartphones, smart TVs, wearables, and connected appliances continue to drive front-end silicon wafer starts. Simultaneously, the automotive sector's transition to zone-architecture vehicles and 800 V EV platforms dramatically increases semiconductor content per vehicle, amplifying demand for reliable high-temperature oxidation steps.
2. Electrification and wide-bandgap device ramp The structural shift toward silicon carbide (SiC) and gallium nitride (GaN) power devices for EV inverters, onboard chargers, and renewable-energy systems creates new requirements for specialized high-temperature oxidation (>1300 °C) and post-implant anneal processes that conventional

silicon furnaces cannot adequately address.

Key Restraints

Shortage of qualified process and maintenance engineers Operating modern vertical and high-temperature furnaces demands deep expertise in thermal uniformity, contamination control, and gas-phase reaction kinetics. The persistent talent gap elevates operating cost and risk for both IDMs and foundries, particularly in emerging fabrication clusters.

Notable Equipment Platforms

Centrotherm c.OXIDATOR: A high-temperature oxidation system optimized for SiC processing up to 1500 °C while retaining compatibility with silicon wet and dry oxidation. Multiple configurations support wafer sizes up to 200 mm with emphasis on reduced carbon footprint and operational flexibility.

ASM International SONORA: A 300 mm vertical furnace platform designed for logic and memory applications under atmospheric and LPCVD conditions. The system prioritizes productivity per kilowatt, low particle performance, and simplified serviceability.

Regional Dynamics

Asia-Pacific continues to dominate installed base and new system placements, driven by the region's unmatched concentration of leading-edge logic foundries, memory manufacturers, and power-device fabricators.

China maintains the world's largest electronics and automotive semiconductor consumption base while aggressively expanding domestic front-end capacity.

Taiwan, South Korea, and Japan anchor the most advanced nodes and compound-semiconductor production, ensuring sustained pull for next-generation oxidation and anneal equipment.

India's accelerating domestic electronics and automotive component ecosystem is emerging as an additional high-growth pocket.

North America and Europe exhibit more moderate expansion, fueled primarily by power-device, analog, and specialty IC production alongside incremental capacity additions for automotive-grade and defense-qualified silicon. The U.S. resurgence in 200 mm and 300 mm fabrication, combined with CHIPS Act-related investments, supports steady replacement and greenfield demand.

Overall, the semiconductor oxidation furnace market remains on a solid growth trajectory, propelled by structural increases in automotive semiconductor content, the ongoing SiC/GaN ramp, and persistent consumer electronics volume. Systems capable of delivering atomic-scale uniformity across larger wafers and higher processing temperatures will capture disproportionate value as the industry pushes toward GAA nanosheets, backside power delivery, and wide-bandgap integration.

Key Benefits of this Report:

Insightful Analysis: Gain detailed market insights covering major as well as emerging geographical regions, focusing on customer segments, government policies and socio-economic factors, consumer preferences, industry verticals, and other sub-segments.

Competitive Landscape: Understand the strategic maneuvers employed by key players globally to understand possible market penetration with the correct strategy.

Market Drivers & Future Trends: Explore the dynamic factors and pivotal market trends and how they will shape future market developments.

Actionable Recommendations: Utilize the insights to exercise strategic decisions to uncover new business streams and revenues in a dynamic environment.

Caters to a Wide Audience: Beneficial and cost-effective for startups, research institutions, consultants, SMEs, and large enterprises.

What do businesses use our reports for?

Industry and Market Insights, Opportunity Assessment, Product Demand Forecasting,

Market Entry Strategy, Geographical Expansion, Capital Investment Decisions, Regulatory Framework & Implications, New Product Development, Competitive Intelligence

Report Coverage:

Historical data from 2021 to 2025 & forecast data from 2026 to 2031

Growth Opportunities, Challenges, Supply Chain Outlook, Regulatory Framework, and Trend Analysis

Competitive Positioning, Strategies, and Market Share Analysis

Revenue Growth and Forecast Assessment of segments and regions including countries

Company Profiling (Strategies, Products, Financial Information, and Key Developments among others.

Semiconductor Oxidation Furnace Market Segmentation:

By Furnace Type

Horizontal

Vertical

By Process

Wet Oxidation

Dry Oxidation

Others

By Wafer Size

Up to 100 mm

100 to 200 mm

Greater than 200 mm

By Application

Integrated Circuits

Discrete Devices

Others

By Geography

Americas

USA

Europe Middle East and Africa

Germany

United Kingdom

Netherlands

Others

Asia Pacific

China

Japan

South Korea

Taiwan

Others

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